

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

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Title of Invention

ALTERNATING PHASE MASK BUILT BY ADDITIVE FILM
DEPOSITION

Application Number :

Confirmation Number:

First Named Applicant: Toshiharu Furukawa

Attorney Docket Number: FIS920030300

Art Unit:

Examiner:

Search string: (4468420 or 4693916 or 4770901 or 4882183 or 5073408 or 5114760 or 5132140
or 5614270 or 5648128 or 5661051 or 6251753 or 6294832).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
	1	4468420	1984-08-28	Kawahara et al.			
	2	4693916	1987-09-15	Nagayama et al.			
	3	4770901	1988-09-13	Katoh et al.			
	4	4882183	1989-11-21	Ino et al.			
	5	5073408	1991-12-17	Goda et al.			
	6	5114760	1992-05-19	Takemura et al.			
	7	5132140	1992-07-21	Goda et al.			
	8	5614270	1997-03-25	Yeh et al.			
	9	5648128	1997-07-15	Yeh et al.			
	10	5661051	1997-08-26	Yeh et al.			
	11	6251753	2001-06-26	Yeh et al.			
	12	6294832	2001-09-25	Yeh et al.			

Signature

Examiner Name	Date